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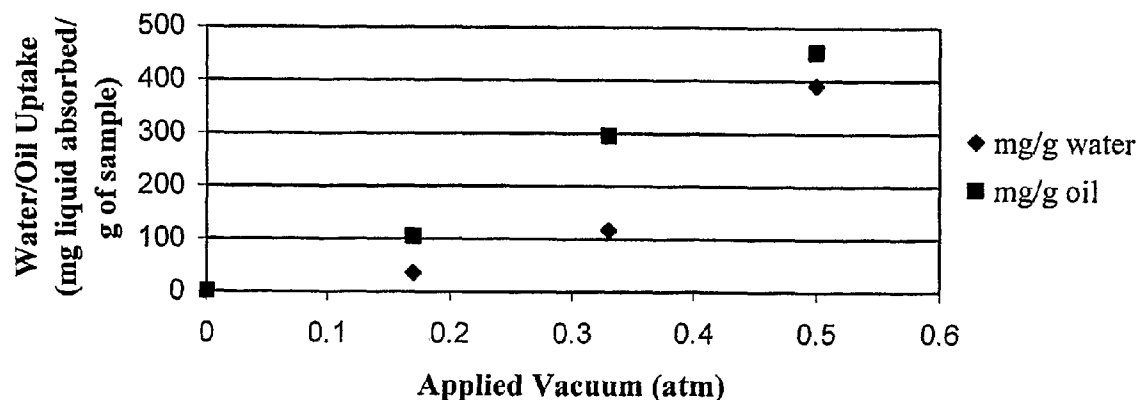
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(54) Title: CMP POROUS PAD WITH COMPONENT-FILLED PORES



(57) Abstract: The invention provides a polishing pad comprising a polymeric material having pores and a component that is disposed within the pores, as well as a method of polishing a workpiece with the aforesaid polishing pad, and a method for producing the aforesaid polishing pad.

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